

Mimicking the Silicon Surface: Reactivity of Silyl Radical Cations toward Nucleophiles [*Journal of the American Chemical Society* **2011**, *133*, 4998–5008 DOI: 10.1021/ja110844e].
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Page 4999, Figure 2. Structures **2** and **3** are depicted as having a vertically oriented trimethylsilyl group at the central Si–H unit. However, this should be a methyl moiety, as indicated throughout the rest of the text. The corrected Figure 2 is shown here.

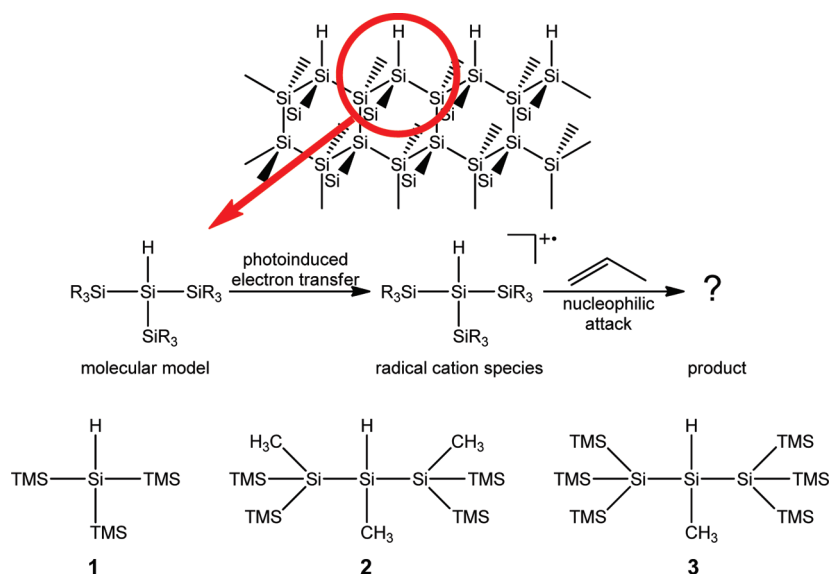


Figure 2. Representation of the selection of the models used in the current study (1–3) and the subsequent study of the silyl radical cations. Note: TMS = $\text{Si}(\text{CH}_3)_3$.

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